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A high-efficiency NiFeSe₄/NiSe₂ bifunctional electrocatalyst with outstanding oxygen evolution reaction and overall water splitting performance†

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Developing cost-effective electrocatalysts for overall water splitting is an effective approach to produce green hydrogen and oxygen. A NiFeSe₄/NiSe₂ heterostructure catalyst for high-efficiency HER and OER was effectively created using an *in situ* growth preparation approach in this study. The basic crystal structure of the material was altered by selenization, which facilitates electron redistribution within the material. Furthermore, the heterostructure formed following selenization can not only improve the material's conductivity but also give additional active area for catalysis. Meanwhile, the built-in electric field aided in electron redistribution. The NiFeSe₄/NiSe₂-8 h catalyst demonstrated excellent performance, requiring an overpotential of only 218 mV (OER) and 121 mV (HER) to achieve a current density of 10 mA cm⁻². The overall water splitting reaction was carried out at 1.572 V using the NiFeSe₄/NiSe₂-8 h bifunctional catalyst as the cathode and anode of the reaction. Stability is also an important component in determining the quality of materials. The NiFeSe₄/NiSe₂-8 h material reacted continuously at diverse current densities (including low and high current densities) for 36 h with no noticeable performance loss. This work provides a feasible method for preparing an economical and efficient electrocatalyst by adjusting the electrocatalytic performance through heterojunction engineering.

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Introduction

Electrocatalytic water splitting is seen as an effective way to generate green hydrogen and oxygen, which is essential in addressing the energy shortage and environmental contamination caused by carbon discharges.^{1–3} Harnessing wind, tidal, and other renewable, clean energy sources to generate energy for the purpose of water splitting is seen as an encouraging approach.^{4,5} As the product of water splitting, hydrogen has the advantages of clean combustion products, being renewable, and high energy density.^{4,6–9} The water splitting reaction consists of two half reactions, the cathodic HER reaction with two-electron transfer and the anodic OER reaction with four-electron transfer.^{6,8,10–15} Both half-reactions require extra energy to surpass the reaction barrier, thereby demanding effective catalysts to diminish the reaction's overpotential.^{8,10,16} Prior research studies have demonstrated the low overpotentials and good catalytic activity of noble metal-based catalysts, including RuO₂, IrO₂, and Pt, indicating their potential utility as effective water splitting catalysts.^{7,10,17–20} Nevertheless, their extensive utilization is constrained by their

limited availability, exorbitant cost, and low durability.^{6,7,10,17,21,22} Therefore, economical, effective and reliable bifunctional catalysts are essential.

Due to their abundance in the earth, low cost, and good electrocatalytic performance, transition metal (TM) compounds have been prepared as HER and OER electrocatalysts in recent years.²³ Among them, NiFe layered double hydroxides (NiFe-LDH) exhibit good catalytic activity in the OER, even surpassing some noble metal catalysts.^{15,24–26} However, due to the slow water dissociation kinetics of this catalyst, there is a problem of poor catalytic activity for the HER.²⁴ Simultaneously, NiFe-LDH has a limited surface area and low electrical conductivity, which leads to a high voltage for water splitting.^{13,24,25} Selenide exhibits superior electrical conductivity compared to other transition metals.^{27–29} Transition metal selenides (TMSes) possess comparable structures to sulfides. However, Se atoms possess a greater atomic radius,²⁷ superior metallic properties, and lower ionization energy compared to S atoms, thereby enabling selenides to demonstrate superior conductivity compared to sulfides and a suitable electron configuration.³⁰ Among TMSes, NiSe₂ has high intrinsic conductivity, but its further applications are hindered by the shortcomings of low catalytic activity, small surface area, and poor durability.^{27,31}

Consequently, to enhance the efficiency of catalysts, doping,³² alloying,³³ and heterostructures^{34,35} are commonly

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employed. Among them, using heterostructures is an effective method.^{28,36,37} In heterojunction catalysts, electrons are rearranged on the heterojunction interface to modify the active sites, and the synergistic effect of different active sites can promote the reaction kinetics.³⁸ In addition, heterojunctions can enable different components to maintain their respective properties.³⁹ The catalyst's improved catalytic activity can be attributed to the robust electronic interaction among its various components.³⁶ Extensive heterostructure interfaces increase the electrochemically active area,²⁸ fully expose the active sites, and hence enhance the catalytic activity.³⁶ For instance, Tan *et al.*³⁵ successfully synthesized NiSe₂/Ni₃Se₄ biphasic catalysts with good water splitting and HER performance. Interfacial electron transport was facilitated by the catalyst's heterogeneous structure. This heterostructure's effective construction raised the adsorption/desorption energy in addition to improving the conductivity.

In this work, a heterostructure of NiFeSe₄/NiSe₂ has been successfully designed and synthesized by a sensible strategy. The hetero-interfacial interaction between NiFeSe₄ and NiSe₂ provided a strong synergistic effect, which enhanced the interfacial charge transfer and electrical conductivity, which was beneficial to enhancing the performance of the catalyst. The NiFeSe₄/NiSe₂-8 h catalyst had excellent electrocatalytic performance. The HER and OER processes can occur at overpotentials of just 121 mV and 218 mV, respectively, with a current density of 10 A cm⁻². When the NiFeSe₄/NiSe₂ bifunctional electrode was used as the cathode and anode, the water splitting reaction could only be conducted at a voltage of 1.572 V. Afterwards, at different current densities (10, 100 and 300 mA cm⁻²), overall water splitting was performed, and the performance did not decrease significantly within 36 h.

Experimental

Synthesis of the materials

Experimental reagents. The Tianjin Damao Chemical Reagent Plant provided 98.0% pure nickel nitrate hexahydrate (Ni(NO₃)₂·6H₂O). McLean Co., Ltd was the source of the 99% pure iron nitrate (Fe(NO₃)₂·9H₂O). Selenium was procured from Shanghai Meixing Chemical Co., Ltd. Sinopharm Chemical Reagent Co., Ltd provided us with ammonium fluoride (NH₄F), borohydride sodium (NaBH₄), urea (CH₄N₂O), and ethanol (CH₃CH₂OH). CLP Technology Co., Ltd was the source of the nickel foam (99% Ni, porosity up to 97%). Every chemical was of analytical grade and did not require any further purification.

Synthesis of NiFe-LDH. The NiFe-LDH catalyst was prepared by a hydrothermal method. First, NF (2 × 4 cm²) was pretreated. The surface oxidation layer was removed by soaking in hydrochloric acid aqueous solution (2 M), then ultrasonic cleaning was carried out with deionized water and ethanol, respectively. Finally, the processed material was dried. Next, 12 mmol urea, 4.8 mmol NH₄F, 0.33 mmol Fe(NO₃)₂·9H₂O and 2.31 mmol Ni(NO₃)₂·6H₂O were weighed and put into a beaker, and 100 ml deionized water was added. The prepared solution was stirred for 30 minutes, and then it was put into a reactor together with NF for reaction. Heating was performed at 120 °C for 8 h. After

the reaction was completed, the reaction kettle was naturally cooled to room temperature. The materials were then removed from the Teflon-lined autoclave and rinsed with deionized water. The material was then placed in a vacuum drying oven and dried at 60 °C.

Synthesis of NiFeSe₄/NiSe₂. The NiFeSe₄/NiSe₂ catalyst was prepared by a solvothermal method. First, 60 ml of ethanol was bubbled with N₂ for 20 min, and then 1.7 mmol NaBH₄ and 0.75 mmol of selenium were reacted in 3 ml of deionized water to form a transparent liquid and put into a Teflon-lined autoclave together with the above-mentioned prepared NiFe-LDH. The reaction time was 6 h, 8 h or 10 h at 140 °C. Following the reaction, the samples were repeatedly rinsed with deionized water, and then allowed to dry in a vacuum drying oven at 60 °C for 9 h. According to the different reaction times, the obtained samples were named NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-8 h, and NiFeSe₄/NiSe₂-10 h.

Material characterization

A TESCAN MIRA LMS scanning electron microscope (SEM) was utilized to capture images of the sample's morphology and conduct mapping tests. XRD (Ultima IV) was used to analyze the physical composition of the materials. A Thermo Scientific K-Alpha XPS instrument was utilized to assess the valence state of the materials. The XPS instrument utilized Al K α rays and underwent calibration with surface-contaminated C 1s as a benchmark. Lattice information and high-resolution TEM (HRTEM) images of the material were obtained using an FEI Talos F200x transmission electron microscope (TEM).

Electrochemical measurements

The prepared materials underwent a series of basic electrochemical tests on a Shanghai Chenhua Electrochemical Workstation (CHI 760E). The electrolyte used in the three-electrode electrolyzer was a 1 M KOH solution, a silver chloride (Ag/AgCl) electrode was used as the reference electrode, and a platinum sheet was used as the counter electrode. No *iR* compensation was conducted in any of the tests included in this study. The electric double layer capacitance (*C*_{dl}) of the different materials was measured using cyclic voltammetry (CV) in the voltage range of 0.923–1.123 V *vs.* RHE. The CV scan rate was from 75 mV s⁻¹ to 200 mV s⁻¹, with increases of 25 mV s⁻¹. The frequency range assessed in electrochemical impedance spectroscopy (EIS) was from 1 × 10⁵ Hz to 1 × 10⁻³ Hz. Stability tests were conducted through chronoamperometry. The data measured during the experiment were converted into an electrode potential relative to the reversible hydrogen electrode (RHE) according to the formula: *E* (*vs.* RHE) = *E* (*vs.* Ag/AgCl) + 0.197 V + 0.05916 × pH. All electrochemical tests were carried out with a potential sweep speed of 5 mV s⁻¹.

Results and discussion

Morphological and structural characterization

Fig. 1 shows the preparation process of the NiFeSe₄/NiSe₂ catalyst. NiFe-LDH nanosheets were synthesized on high-purity

NF using an *in situ* growth method, and then selenized to successfully synthesize the $\text{NiFeSe}_4/\text{NiSe}_2$ catalysts. NF had good electrical conductivity, good stability and a porous structure, which can provide an excellent substrate for subsequent growth of the materials. First, uniformly grown NiFe-LDH nanosheets were successfully prepared on NF by a hydrothermal method. Then, the $\text{NiFeSe}_4/\text{NiSe}_2$ heterostructure was successfully constructed by solvothermal selenization of NiFe-LDH . Finally, $\text{NiFeSe}_4/\text{NiSe}_2$ materials with different morphologies were synthesized through different selenization times.

The morphology of the different materials was characterized. The aforesaid process was used to successfully create $\text{NiFeSe}_4/\text{NiSe}_2$ heterostructures. The SEM image in Fig. 2 shows the surface characteristics of $\text{NiFeSe}_4/\text{NiSe}_2$. Due to the different selenization times, the morphology of the catalysts also had certain differences. Before selenization, NiFe-LDH nanosheets were produced uniformly on smooth NF. Fig. S1† depicts the precursor's SEM. The NF surface was smooth (Fig. S1a and b†), whereas the NiFe-LDH sample formed following hydrothermal reaction had a flake structure (Fig. S1c and d†). The solvothermal method was used to selenize the NiFe-LDH nanosheets. Among these, the addition of Se ions broke down the NiFe-LDH crystal structure, resulting in the dissociation of some Ni ions in the solvent and a Ni source for the NiSe_2 particles that subsequently formed on the surface. Fig. 2 shows SEM images of the surface properties of $\text{NiFeSe}_4/\text{NiSe}_2$. Fig. 2a–c depict the morphology of the catalysts after 6 h, 8 h, and 10 h of selenization, with magnified SEM images added. The nanosheets were clearly related to the nanoparticles, and as the selenization period increased, the nanoparticles on the surface showed an increasing trend. A shorter selenization time may result in an incomplete reaction, whereas a longer selenization time will result in the formation of more NiSe_2 nanoparticles, which may obstruct gas escape. As a result, materials made with

an 8 hour selenization period had better characteristics than materials prepared with a 6 or 10 hour one. More information about the surface characteristics of the material with an 8 hour selenization time can be found in Fig. 2d–f. This reaction resulted in the formation of NiSe_2 and NiFeSe_4 . As a result, the $\text{NiFeSe}_4/\text{NiSe}_2$ heterojunction structure was created successfully.

The structure of $\text{NiFeSe}_4/\text{NiSe}_2$ -8 h was analyzed by TEM and HRTEM. The TEM image showed that $\text{NiFeSe}_4/\text{NiSe}_2$ -8 h had a structure in which the nanosheets and nanoparticles were connected, corresponding to the SEM image. A closer look at Fig. 3a revealed distinct lattice fringes. The lattice spacing corresponding to the two cross-sections was clearly seen in Fig. 3b. The (220) crystal plane of NiSe_2 was represented by the lattice spacing of 0.300 nm, while the (220) crystal plane of NiFeSe_4 was represented by the lattice spacing of 0.209 nm. Fourier transform (FFT) diffraction pattern images of two selected areas are inserted in Fig. 3c, which facilitates comparison with the results of the lattice spacing. SAED (selected area electron diffraction) was then performed on the $\text{NiFeSe}_4/\text{NiSe}_2$ -8 h material, and the resulting image (Fig. 3d) was analyzed. The diffraction ring marked in green corresponds to NiFeSe_4 , and the diffraction ring marked in yellow corresponds to NiSe_2 . The green ring corresponds to the (211) crystal plane of NiFeSe_4 , which corresponds to the lattice spacing measured in Fig. 3f. The (220) and (311) crystal faces were represented by the yellow rings, respectively, of which the (220) crystal plane can also be clearly seen in Fig. 3f. Fig. 3e is the lattice fringe diagram of $\text{NiFeSe}_4/\text{NiSe}_2$ -8 h, and Fig. 3f analyzes the positions represented by the green squares. From Fig. 3f, in addition to the lattice stripes corresponding to NiFeSe_4 and NiSe_2 , the interface between NiFeSe_4 and NiSe_2 can also be clearly seen. The visible phase boundary between the NiFeSe_4 and NiSe_2 crystals indicates the successful preparation of the heterointerface. Element mapping

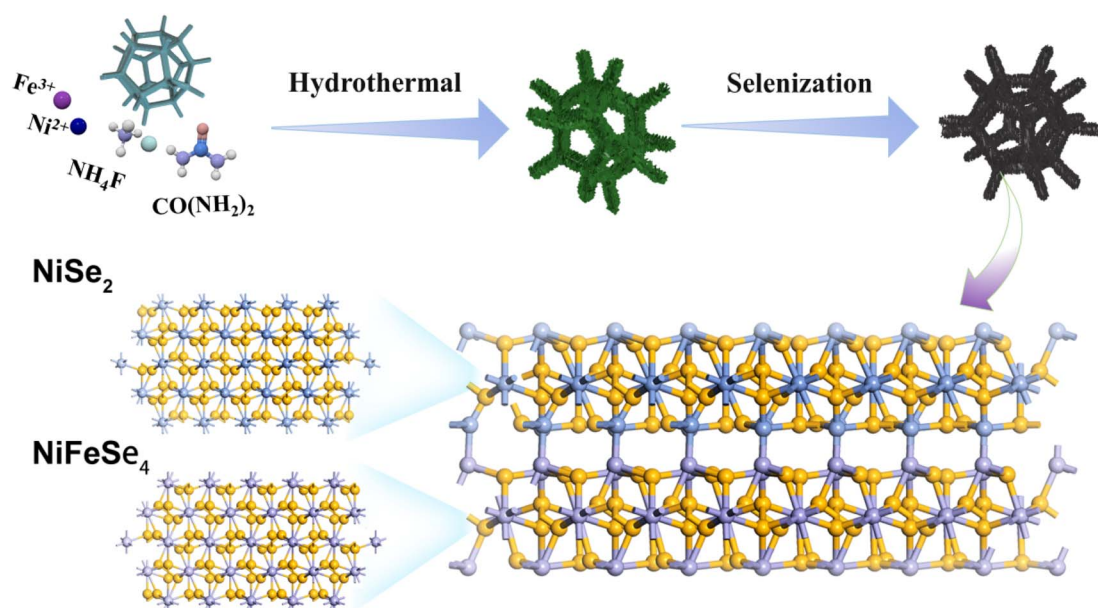


Fig. 1 Synthesis process of $\text{NiFeSe}_4/\text{NiSe}_2$.

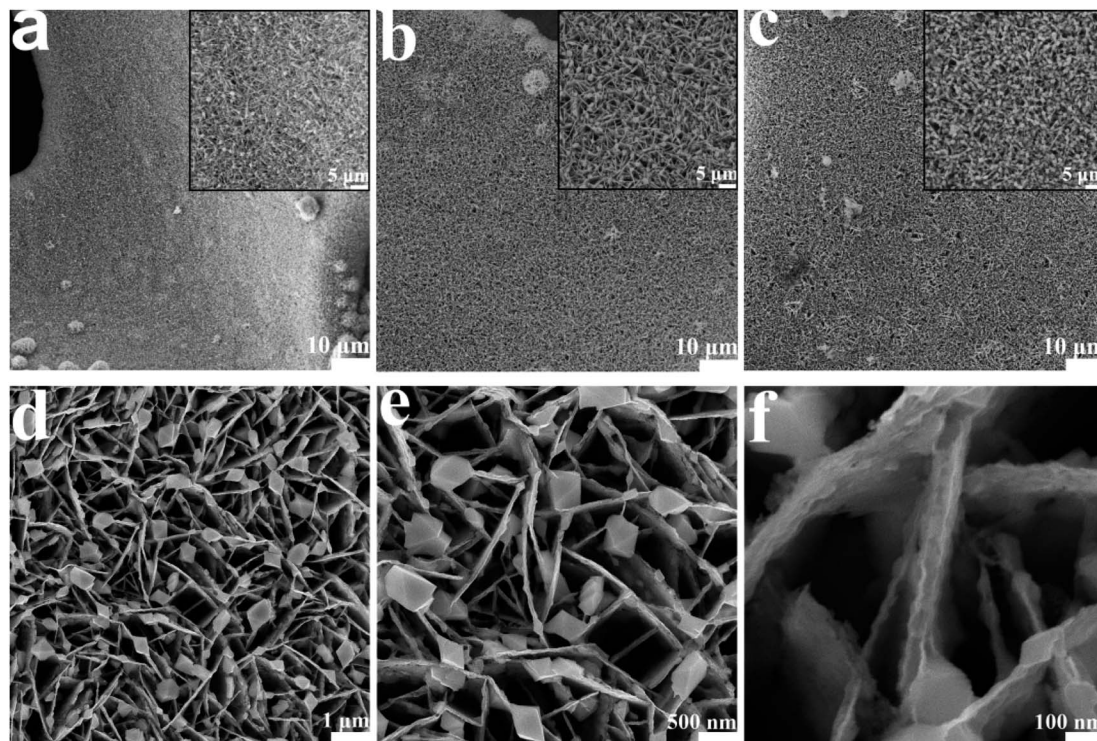


Fig. 2 SEM images of catalysts prepared with different selenization times: (a) NiFeSe₄/NiSe₂-6 h; (b) NiFeSe₄/NiSe₂-8 h; (c) NiFeSe₄/NiSe₂-10 h; (d–f) zoomed-in views of the NiFeSe₄/NiSe₂-8 h.

was performed on the material. It was evident from Fig. 3g that the presence of Ni, Fe and Se elements in NiFeSe₄/NiSe₂-8 h was balanced throughout the material. Table S1 and Fig. S2† clearly show that the material contains Ni, Fe, and Se elements. The graph in Table S1† illustrates the amount of each element in the material. In summary, the successful preparation of the NiFeSe₄/NiSe₂ heterostructure was further demonstrated by TEM.

XRD was used to characterize the phases of NiFe-LDH, NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-8 h, and NiFeSe₄/NiSe₂-10 h, which confirmed that the selenized materials were made of NiFeSe₄ and NiSe₂. For these materials, there were three obvious peaks at $2\theta = 44.605^\circ$, 51.979° , and 76.690° . These three peaks were related to the NF base used. These three peaks matched NF (PDF # 70-0989) (Fig. S3a†) and corresponded to the (111), (200) and (220) crystal planes, respectively. For the material prepared by the hydrothermal method, its spectrum matched well with NiFe-LDH (PDF # 40-0215) (Fig. S3a†). The results demonstrated that NiFe-LDH could be successfully synthesized using the hydrothermal technique. Comparing the spectrum of the material after selenization with NiFe-LDH, it was found that the NiFe-LDH peak disappeared, proving that the composition of the material changed after selenization. Analysis of the selenized materials revealed that $2\theta = 30.040^\circ$, 33.660° and 36.980° match the (200), (210) and (211) crystal planes of NiSe₂ (PDF # 65-5016). It was also found from Fig. 4a that the diffraction related to NiSe₂ gradually increased as the reaction time increased, which indicated that the crystallinity of the NiSe₂ material further increased. Some peaks of the

NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-8 h, and NiFeSe₄/NiSe₂-10 h materials corresponded to NiFeSe₄ (PDF # 97-063-2969), which indicated that the selenized material also contained NiFeSe₄ (Fig. S3b†). NiSe₂ and NiFeSe₄ had similar lattice structures (Fig. S4†), and the difference between them was the atoms at the vertices. The atoms at the vertex of NiSe₂ were all Ni atoms, while the atoms at the vertex of NiFeSe₄ were Ni atoms and Fe atoms, and they occupied 1/2 of the positions of the vertex. Since Fe atoms have a smaller atomic radius than Ni atoms, this may cause the diffraction peak of NiFeSe₄ to move to a position larger than 2θ compared to the diffraction peak of NiSe₂. From this, the content of Fe element in the material was relatively low relative to other elements. Therefore, the ratio of Ni to Fe elements in the NiFeSe₄ material formed by selenization may not be the original 1 : 1 ratio, and the ratio may be greater than 1. Therefore, the diffraction peak of NiFeSe₄ was shifted.

XPS was used to analyze the elements and valence states of the materials. It can be obtained from the full spectra of NiFe-LDH and NiFeSe₄/NiSe₂-8 h (Fig. 4b) that both materials contain Ni and Fe elements, but compared with NiFe-LDH, NiFeSe₄/NiSe₂-8 h also contains Se element. This corresponded to the previous mapping, further proving that the selenized material contained Se element. Fig. 4c–f show the high-resolution XPS spectra of Ni 2p, Fe 2p, Se 3d and O1s of NiFeSe₄/NiSe₂-8 h, respectively. Fig. 4c shows the Ni 2p spectra of the NiFeSe₄/NiSe₂-8 h material and NiFe-LDH, which were fitted. Among them, the fitting peak of 856.15 eV corresponded to Ni 2p_{3/2} of the NiFeSe₄/NiSe₂-8 h material.¹² Compared with Ni 2p_{3/2} (855.85 eV) of the NiFe-LDH material,⁴⁰ it was found

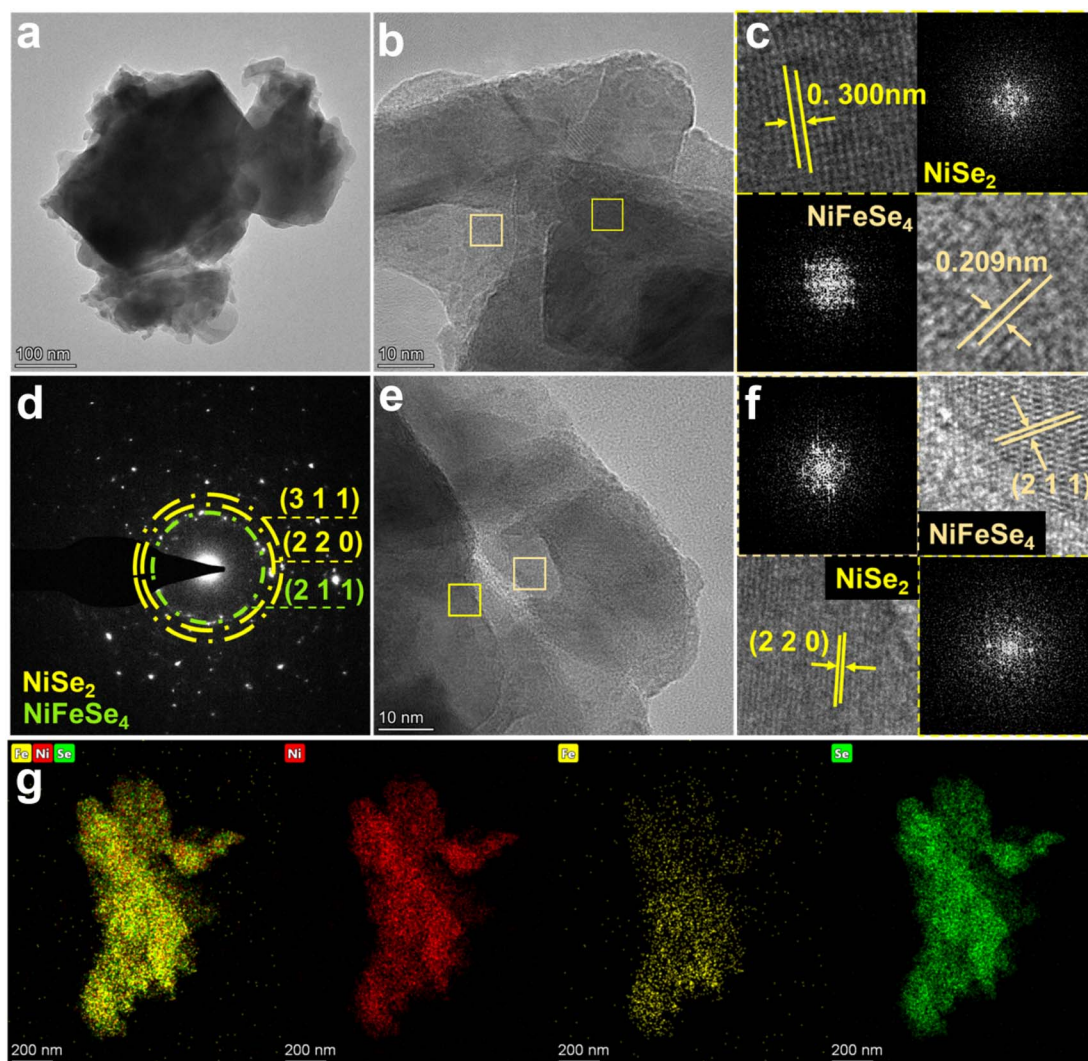


Fig. 3 (a) The NiFeSe₄/NiSe₂-8 h heterostructure stripped from NF and (b) its corresponding HRTEM image; (c) HRTEM corresponding lattice fringes and its FFT pattern; (d) SAED pattern of NiFeSe₄/NiSe₂-8 h; (e) image at the NiFeSe₄/NiSe₂-8 h interface and (f) lattice fringes at the interface; (g) EDS mapping image.

that the selenized material migrated towards a higher binding energy. This phenomenon indicates that the material may have a higher valence state, which also implies that NiFeSe₄/NiSe₂-8 h may have a higher catalytic activity.⁴¹ The peaks at 874.01 eV and 873.67 eV correspond to Ni 2p_{1/2} of the NiFeSe₄/NiSe₂-8 h material and NiFe-LDH material, respectively.⁴⁰ For NiFe-LDH, the other two fitted peaks correspond to satellite peaks. It was possible to see that the selenified material had two more peaks beneath its spectra than NiFe-LDH when comparing the spectra of NiFeSe₄/NiSe₂-8 h and NiFe-LDH. The two peaks at 854.0 and 871.62 eV indicated the formation of Ni–Se bonds in the selenized material,⁴¹ further proving that Se elements were present in the selenized material. The presence of Ni–Se bonds also corresponded to the results of XRD analysis, that was, NiSe₂ existed in the selenized material. The Fe 2p spectrum is depicted in Fig. 4d. The Fe 2p spectral analysis revealed that the fitting peaks at 707.28 eV and 712.45 eV correspond to Fe 2p_{3/2}, while the fitting peaks at 720.28 eV and 725.58 eV correspond to

Fe 2p_{1/2}.^{12,42} Simultaneously, the two fitting peaks at 716.68 eV and 730.58 eV correspond to two satellite peaks.^{12,42} Among them, the Fe³⁺ peak of Fe 2p_{3/2} in NiFeSe₄/NiSe₂-8 h was shifted to a position with lower binding energy compared with NiFe-LDH (712.63 eV). This was due to the addition of greater electronegativity to the substance.¹² The Se atoms made the adjacent Fe atoms of the NiFeSe₄/NiSe₂-8 h catalyst rich in electrons. The Se 3d spectrum of NiFeSe₄/NiSe₂-8 h is depicted in Fig. 4e, with the peak at 55.11 eV representing Se 3d_{5/2} and the peak at 59.39 eV indicating Se 3d_{3/2}.^{41,43} The presence of the peak at 59.39 eV was ascribed to the oxidation peak resulting from the oxidation of the Se surface, which corresponds to the Se–O bond.^{41,43} Furthermore, the O 1s spectrum of the material was fitted to three peaks, which corresponded to water molecules that were adsorbed in a physical manner, M–OH bonds that were adsorbed chemically, and M–O bonds that were adsorbed chemically.^{40,41} In conclusion, the Ni and Fe peaks in NiFeSe₄/NiSe₂-8 h and NiFe-LDH were compared, and it was found that

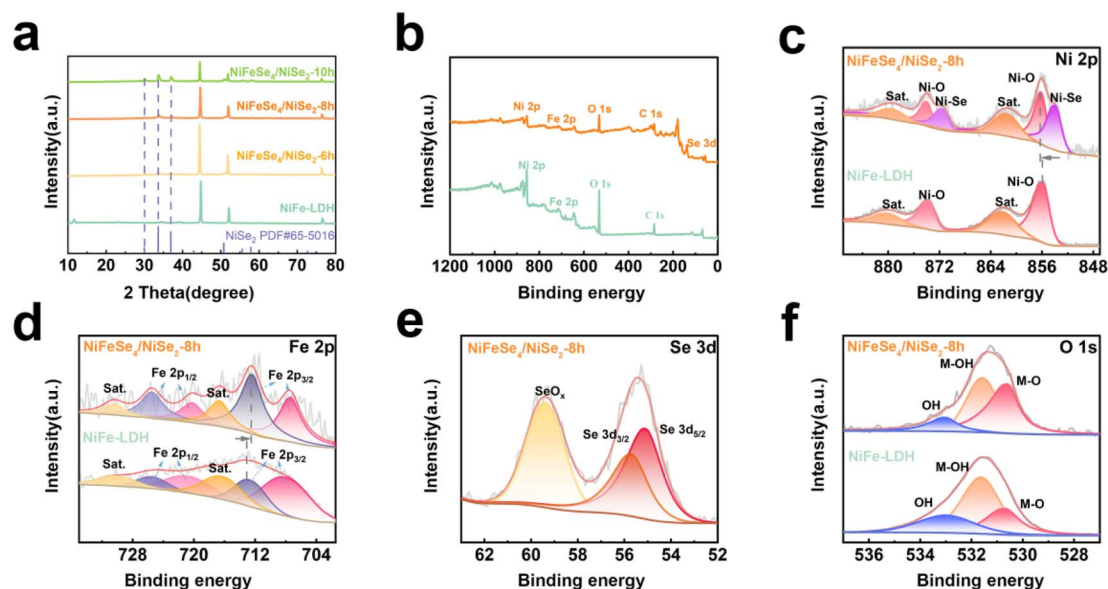


Fig. 4 (a) XRD patterns of NiFe-LDH, NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-8 h, and NiFeSe₄/NiSe₂-10 h; (b) the high-resolution XPS spectra of (c) Ni 2p, (d) Fe 2p, (e) Se 3d and (f) O 1s of NiFe-LDH and NiFeSe₄/NiSe₂-8 h.

the peaks were shifted. This suggested that there may be a redistribution of electrons in the material after selenization, and this distribution may promote the electrocatalytic properties of the material.

Electrochemical OER performance

The OER properties of the NF, NiFe-LDH, NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-8 h and NiFeSe₄/NiSe₂-10 h materials were tested. It was clear from Fig. S7a† that the LSV curves in the positive scan showed a marked oxidation peak at approximately 1.4 V,

which was likely due to the conversion of Ni²⁺ to Ni³⁺. The oxidation peak area of NiFeSe₄/NiSe₂-8 h was larger than that of NiFeSe₄/NiSe₂-6 h and NiFeSe₄/NiSe₂-10 h, suggesting that NiFeSe₄/NiSe₂-8 h produced more active sites.¹² The material's performance was assessed by employing backscan LSV in order to mitigate the impact of the oxidation peaks. Fig. 5a shows the LSV curves of all materials. The NiFeSe₄/NiSe₂-8 h material prepared with a selenization time of 8 h had excellent OER electrocatalytic activity. When the overpotential was 218 mV, the OER reaction can take place at 10 mA cm⁻² current

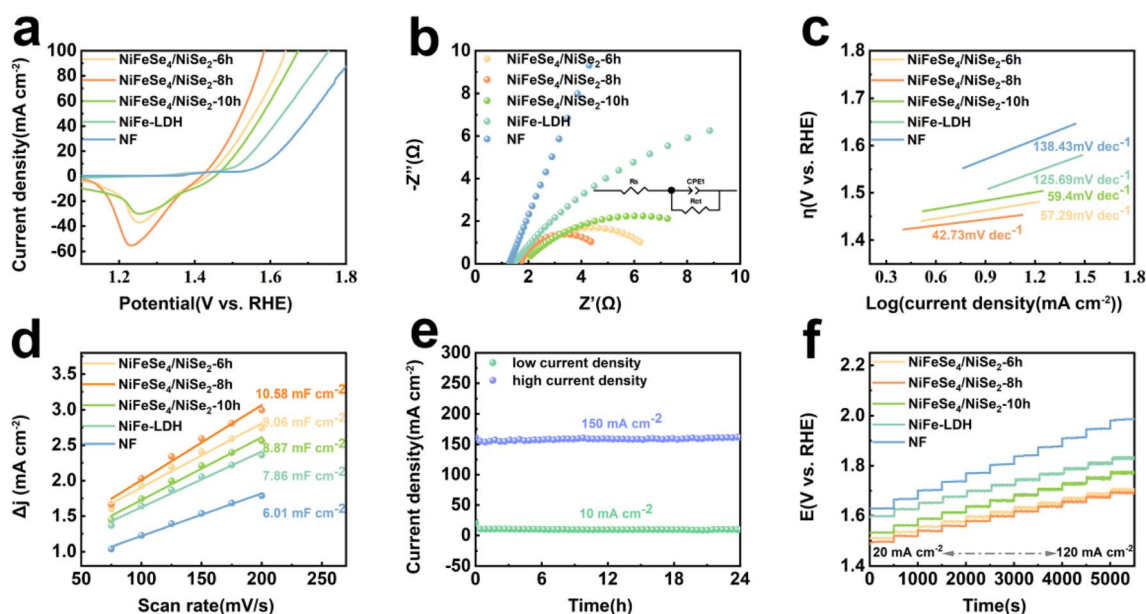


Fig. 5 OER performance of catalytic electrodes NF, NiFe-LDH, NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-8 h and NiFeSe₄/NiSe₂-10 h: (a) LSV curves; (b) Nyquist diagram; (c) Tafel diagram; (d) C_{dl} measurement; (e) stability tests at high and low current densities; (f) multi-potential step.

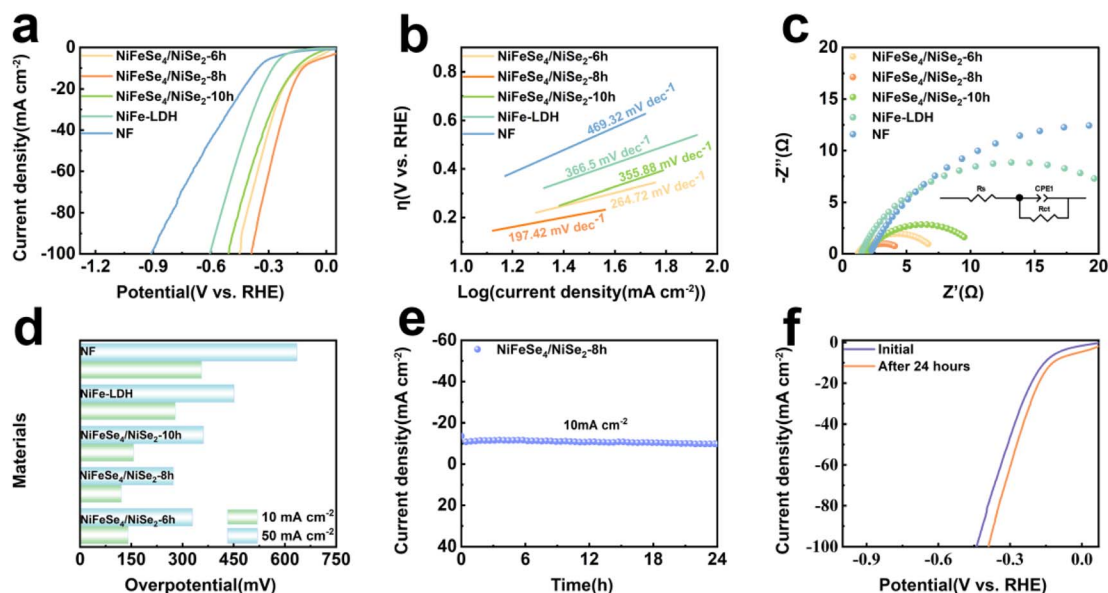


Fig. 6 HER performance of the catalytic electrodes NF, NiFe-LDH, NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-8 h and NiFeSe₄/NiSe₂-10 h: (a) LSV curves; (b) Tafel diagram; (c) Nyquist diagram; (d) different current densities corresponding to overpotential; (e) stability test diagram; (f) performance comparison diagram before and after reaction.

density, which was lower than NF (355 mV), NiFe-LDH (291 mV), NiFeSe₄/NiSe₂-6 h (237 mV) and NiFeSe₄/NiSe₂-10 h (258 mV).

The charge transfer between the material and the electrolyte was studied using EIS, and the interfacial dynamics of the OER reaction were further investigated. The Nyquist curves of NF, NiFe-LDH, NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-8 h and NiFeSe₄/NiSe₂-10 h are depicted in Fig. 5b. The obtained curves were calculated according to the equivalent circuit model (Fig. S5†) for fitting. The impedance plot without equivalent circuit fitting is shown in Fig. S10a.† Fig. 5b indicates that the NiFeSe₄/NiSe₂-8 h half-circles are smaller than those of the other samples, indicating that NiFeSe₄/NiSe₂-8 h had the least amount of charge transfer resistance and the most conductivity. The data in Table S2† indicate that NiFeSe₄/NiSe₂-8 h had a reduced charge transfer resistance and a high charge transfer capacity. The NiFeSe₄/NiSe₂-8 h heterojunction structure reduced the R_{ct} values, improved the electron transfer rate and improved the OER performance. The ohmic resistance of NiFeSe₄/NiSe₂-8 h was 3.279 Ω , indicating that NiFeSe₄/NiSe₂-8 h was in good contact with the electrolyte and had minimal resistance to the electrolyte. The LSV results in Fig. 5c indicate that NF (138.43 mV dec⁻¹), NiFe-LDH (125.69 mV dec⁻¹), NiFeSe₄/NiSe₂-6 h (57.29 mV dec⁻¹), NiFeSe₄/NiSe₂-10 h (59.4 mV dec⁻¹), and NiFeSe₄/NiSe₂-8 h (42.73 mV dec⁻¹) were the phases with the lowest Tafel slope, which significantly improved the OER activity and kinetics. The lower the Tafel slope, the quicker the catalyst's speed and the more effective the substance's catalytic activity, which was in agreement with the Nyquist curves' findings. Simultaneously, the Tafel slope indicated data regarding the catalytic process. The OER reaction was a four-electron transfer process, which sequentially formed the intermediates OH*, O*, and OOH*. When the Tafel slope was between 40 and 60 mV dec⁻¹, it indicated that the limiting pace of the material

was the formation of O-O bonds (OOH*).⁴⁴ The Tafel slope of NiFeSe₄/NiSe₂-8 h lay in this interval, so the rate limiting step of this material was the formation of OOH*. The C_{dl} of the material was then studied using CV repeated cycle tests. Fig. S6† shows the CV scan images of different materials. Fig. 5d shows that the C_{dl} values of NF, NiFe-LDH, NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-8 h and NiFeSe₄/NiSe₂-10 h were 6.01, 7.86, 9.06, 10.58 and 8.87 mF cm⁻², respectively. Compared with the other materials, NiFeSe₄/NiSe₂-8 h had a larger electrochemically active area. The LSV curves were normalized using the ESCA, and Fig. S7b† shows the normalized data. As can be seen from Fig. S7b,† NiFeSe₄/NiSe₂-8 h still had excellent performance in the normalized LSV curves.

The material stability of the OER catalysts was also taken into consideration when assessing their performance, in addition to their good OER capabilities. The stability test of NiFeSe₄/NiSe₂-8 h at 10 mA cm⁻² and 100 mA cm⁻² is demonstrated in Fig. 5e. From the fact that there was no obvious downward trend in the curve in the figure, it was concluded that NiFeSe₄/NiSe₂-8 h had good stability. The surface shape of the NiFeSe₄/NiSe₂-8 h material did not change considerably after 24 h of stability testing, as shown in Fig. S7d.† The LSV test of NiFeSe₄/NiSe₂-8 h following the stability test was compared to the LSV test conducted before the test (Fig. S7c†). The LSV curve after the stability test and the curve before the test were basically consistent, indicating that the material had good OER stability. The NF, NiFe-LDH, NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-8 h and NiFeSe₄/NiSe₂-10 h working electrodes were tested at various current densities (ranging from 20 mA cm⁻² to 120 mA cm⁻², increasing by 10 mA cm⁻²) at 500 second intervals. NiFeSe₄/NiSe₂-8 h had the lowest initial voltage compared to the other materials, and yielded similar outcomes regardless of the current density. In the experiment, NiFeSe₄/NiSe₂-8 h exhibited

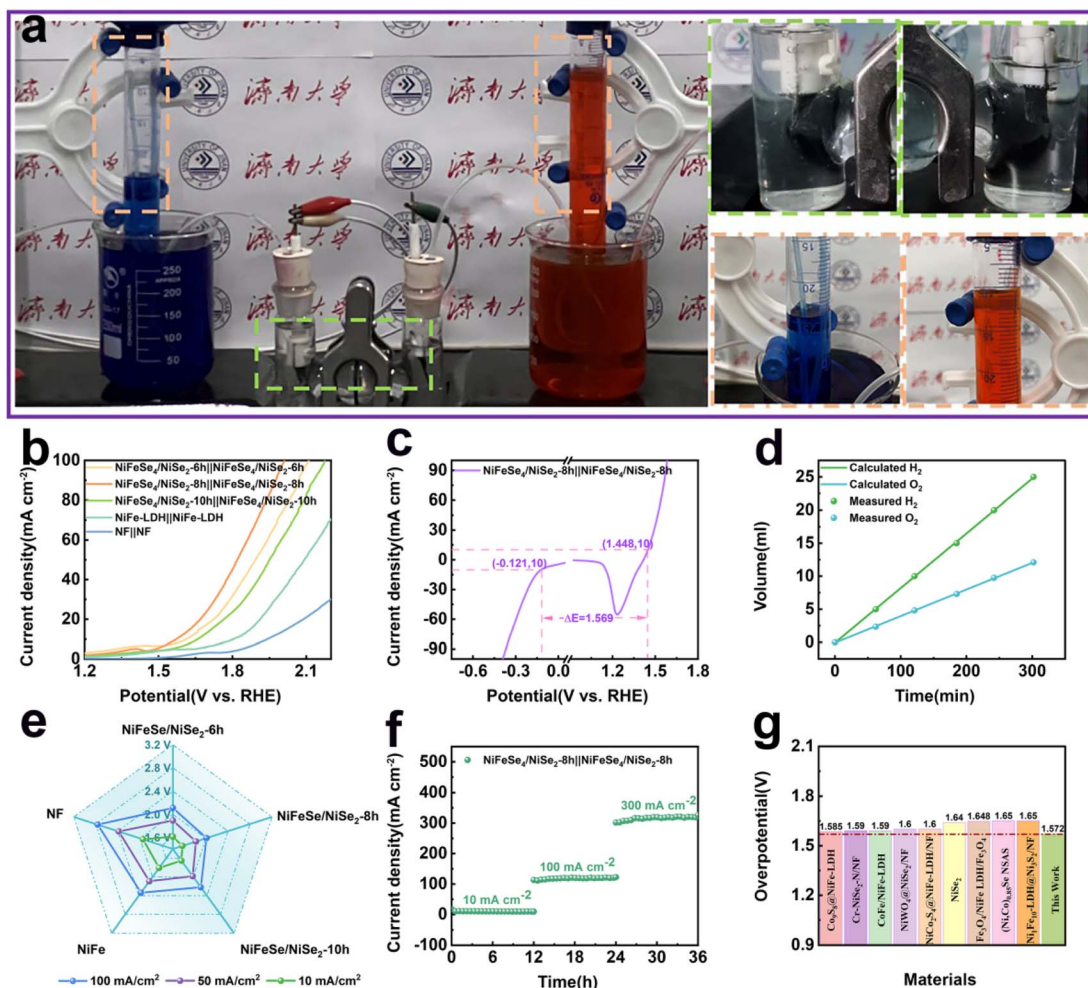


Fig. 7 Overall water splitting performance of different materials in the double-electrode system: (a) the $\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}||\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}$ double-electrodes system for overall water splitting and gas collection; (b) polarization curves; (c) $\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}$ LSV curves for the OER and HER; (d) the volumes of H_2 and O_2 experimentally measured and theoretically calculated versus time at 20 mA cm^{-2} ; (e) different current densities corresponding to overpotential; (f) stability test; (g) comparison with other overall water splitting works.

impressive catalytic activity and demonstrated satisfactory performance and steadiness when subjected to multi-level progressive current density.

Electrochemical HER performance

Then, the HER performance of NF, NiFe-LDH , $\text{NiFeSe}_4/\text{NiSe}_2\text{-}6\text{ h}$, $\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}$ and $\text{NiFeSe}_4/\text{NiSe}_2\text{-}10\text{ h}$ was tested. The LSV curves (Fig. 6a) demonstrated that $\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}$ (121 mV) had an overpotential of 10 mA cm^{-2} current density. When compared to NiFe-LDH (279 mV), $\text{NiFeSe}_4/\text{NiSe}_2\text{-}6\text{ h}$ (141 mV), and $\text{NiFeSe}_4/\text{NiSe}_2\text{-}10\text{ h}$ (157 mV), the overpotential of $\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}$ was small. The Tafel slope was calculated from the LSV curves of the different materials (Fig. 6b). Fig. 6d shows the HER performance of each material in greater detail. The Tafel slope of $\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}$ ($197.42\text{ mV dec}^{-1}$) was lower than that of NF ($469.32\text{ mV dec}^{-1}$), NiFe-LDH (366.5 mV dec^{-1}), $\text{NiFeSe}_4/\text{NiSe}_2\text{-}6\text{ h}$ ($264.72\text{ mV dec}^{-1}$) and $\text{NiFeSe}_4/\text{NiSe}_2\text{-}10\text{ h}$ ($355.88\text{ mV dec}^{-1}$) among the other compounds.

Subsequently, the Nyquist curves of the various materials were evaluated. The equivalent circuit (Fig. S5†) was used for fitting. The impedance plot without equivalent circuit fitting is shown in Fig. S10b.† The Nyquist curve (Fig. 5c) indicated that $\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}$ had the tiniest semicircle. The Nyquist curve depicted a semicircle, which symbolizes the resistance to R_{ct} between the electrode and the electrolyte.⁴⁵ Therefore, the smallest semicircle indicated that $\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}$ had the lowest R_{ct} value, indicating that its charge transfer kinetics and conductivity were the fastest. In addition, the stability test of $\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}$ was conducted for 24 h. Fig. 6e shows that the performance of $\text{NiFeSe}_4/\text{NiSe}_2\text{-}8\text{ h}$ had not changed significantly. Fig. 6f indicates that the material parameters before and after the stability test vary very little. Fig. S8† shows images from the SEM of the material, which indicated that the shape of the material did not change considerably following the stability test. It was proved that the material had good stability, corresponding to the results obtained in Fig. 6e.

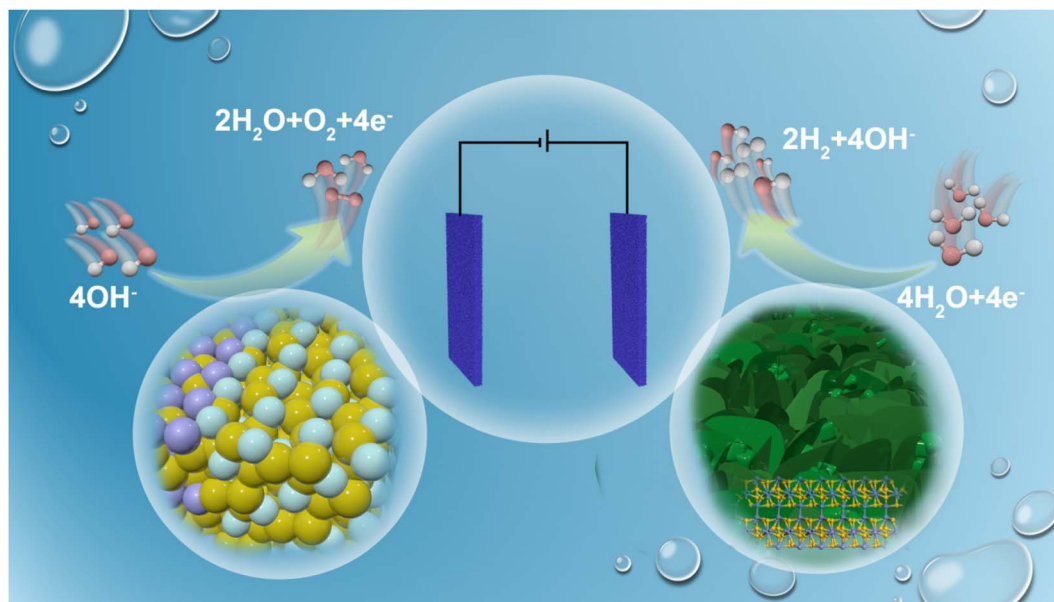


Fig. 8 Schematic diagram of overall water decomposition.

Overall water splitting performance

The NiFeSe₄/NiSe₂-8 h catalyst electrode demonstrated impressive catalytic performance in both OER and HER experiments. Consequently, we conducted a double-electrode alkaline water splitting experiment with the catalyst that had been prepared as a functional electrode. Fig. 7a depicts a mechanism for the water splitting and collection of gas. When the cell's voltage was applied at both ends, a huge volume of H₂ and O₂ gas was created near the cathode and anode, respectively. The volume ratio of H₂ and O₂ produced can be determined by gathering the gas produced and comparing it with the theoretical volume ratio of H₂ and O₂ generated through overall water splitting (2 : 1). As can be seen from the data in Fig. 7d, the amount collected was close to that expected, indicating that the NiFeSe₄/NiSe₂-8 h catalyst did react.

The electrocatalytic properties of the different catalytic electrodes are shown in Fig. 7b. It was evident that the NiFeSe₄/NiSe₂-8 h||NiFeSe₄/NiSe₂-8 h catalytic electrode ratio demonstrated superior electrolytic water splitting capability compared to NiFeSe₄/NiSe₂-6 h||NiFeSe₄/NiSe₂-6 h, NiFeSe₄/NiSe₂-10 h||NiFeSe₄/NiSe₂-10 h, NiFe-LDH||NiFe-LDH and NF||NF. NiFeSe₄/NiSe₂-8 h||NiFeSe₄/NiSe₂-8 h performed water splitting at 1.572 V with a 10 mA cm⁻² current density. Simultaneously, the LSV curves of various materials at high current densities were examined (Fig. S9a†), and NiFeSe₄/NiSe₂-8 h and the other materials created through selenization must attain the same current density at high current densities. The voltage continued to be at its minimum. The overall water splitting performance of each material is depicted in a more accessible manner in Fig. 7e. The three-electrode system test in the alkaline electrolyte test revealed that NiFeSe₄/NiSe₂-8 h had HER and OER overpotentials of -121 mV and 1448 mV relative to RHE when the current density was 10 mA cm⁻², thus indicating

a correlation between the OER and HER of 1.568 V and RHE voltage difference (Fig. 7c).

The catalytic efficiency surpassed all others. Subsequently, the durability of the constructed NiFeSe₄/NiSe₂-8 h||NiFeSe₄/NiSe₂-8 h was examined. The NiFeSe₄/NiSe₂-8 h catalytic electrode in Fig. 7f exhibited robust and long-lasting catalytic stability, with no noticeable decrease in performance after 36 h of uninterrupted operation at room temperature (current densities of 10, 100 and 300 mA cm⁻², respectively, operating at each current density for 12 h). The electrolysis of water was conducted in an industrial setting with a high current density (>200 mA cm⁻², high current density HCD), thus making the stability of the catalyst under HCD a critical factor, and the NiFeSe₄/NiSe₂-8 h catalytic electrode exhibited excellent stability at 300 mA cm⁻².^{46,47} Fig. S9b† shows that the LSV curve of the material before the stability test shows almost no difference from that after the test, which proved that the material has excellent stability. This conclusion echoes previous conclusions reached for the OER and HER. A comparison was made between the two-electrode electrolytic cell composed of NiFeSe₄/NiSe₂-8 h and the electrolytic cell composed of other catalysts at a current density of 10 mA cm⁻². The NiFeSe₄/NiSe₂-8 h necessitated a lower voltage than the one previously reported (Fig. 7g), demonstrating its remarkable catalytic capability.

Excellent overall water splitting performance was present in NiFeSe₄/NiSe₂-8 h. A schematic diagram of the NiFeSe₄/NiSe₂-8 h cathode and anode utilized in the electrolytic cell to carry out a water splitting reaction is shown in Fig. 8. First, the NiFeSe₄/NiSe₂ heterostructure was successfully prepared using an *in situ* growth method on a three-dimensional porous foam substrate, avoiding electron transfer obstacles caused by the use of adhesives and improving the interaction between the material and the substrate. Second, selenization changed the initial

crystal structure of the material and promoted the movement of electrons in the material in a direction that promoted the material properties. The redistribution of electrons meant changes in the valence state of the atoms in the material, and this change would promote the improvement of the material properties. Finally, selenization to form a NiFeSe₄/NiSe₂ heterostructure not only promoted the redistribution of electrons within the material, but also provided a larger active area, which was also of great help in promoting the catalytic performance of the material.

Conclusions

In conclusion, *in situ* growth was used to create NiFeSe₄/NiSe₂-8 h catalytic materials. The characterization analysis showed that we effectively developed a catalytic material with a NiFeSe₄/NiSe₂-8 h heterojunction structure. By altering the selenization time, a heterojunction structure with NiSe₂ uniformly formed on the surface of NiFeSe₄ was produced, with 8 h being the optimal time. To achieve the minimum reaction current density of 10 mA cm⁻² in an alkaline electrolyte, the required overpotentials for NiFeSe₄/NiSe₂-8 h were 218 mV (OER) and 121 mV (HER), respectively. The catalytic activity of the material was enhanced due to the formation of the heterojunction structure after selenization, as well as the redistribution of electrons within the material after selenization. In heterostructures, the development of internal electric fields facilitated the redistribution of electrons. The XPS analysis revealed that the Ni and Fe peaks had shifted, suggesting that the electrons in the vicinity had altered. Furthermore, the performance of NiFeSe₄/NiSe₂-8 h remained largely unchanged even after undergoing continuous HER and OER reactions at a current density of 10 mA cm⁻² for 24 h and OER at a current density of approximately 150 mA cm⁻² for 24 h. Additionally, NiFeSe₄/NiSe₂-8 h was employed as the cathode and anode of the two-electrode electrolyzer, and the performance of continuous operation for 36 h at various current densities showed minimal decline, which was a crucial factor in practical applications. This research showed that by using an *in situ* growth technique to build heterostructure materials, the catalytic performance of these materials was improved, making it a viable option for the production of cost-effective, efficient, and reliable bifunctional catalysts.

Conflicts of interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

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References

- 1 Y. Yang, Y. Kang, H. Zhao, X. Dai, M. Cui, X. Luan, X. Zhang, F. Nie, Z. Ren and W. Song, *Small*, 2020, **16**, 1905083.
- 2 S. Ni, H. Qu, Z. Xu, X. Zhu, H. Xing, L. Wang, J. Yu, H. Liu, C. Chen and L. Yang, *Appl. Catal., B*, 2021, **299**, 120638.
- 3 Y. Du, B. Li, G. Xu and L. Wang, *InfoMat*, 2023, **5**, e12377.
- 4 Y. Huang, L.-W. Jiang, H. Liu and J.-J. Wang, *Chem. Eng. J.*, 2022, **441**, 136121.
- 5 L. Chen, Y. Wang, X. Zhao, Y. Wang, Q. Li, Q. Wang, Y. Tang and Y. Lei, *J. Mater. Sci. Technol.*, 2022, **110**, 128–135.
- 6 X.-P. Li, L.-R. Zheng, S.-J. Liu, T. Ouyang, S. Ye and Z.-Q. Liu, *Chin. Chem. Lett.*, 2022, **33**, 4761–4765.
- 7 P. Wang, Y. Luo, G. Zhang, Z. Chen, H. Ranganathan, S. Sun and Z. Shi, *Nano-Micro Lett.*, 2022, **14**, 120.
- 8 A. Ali, F. Long and P. K. Shen, *Electrochem. Energy Rev.*, 2022, **5**, 1.
- 9 H. Liu, J. Gao, X. Xu, Q. Jia, L. Yang, S. Wang and D. Cao, *Chem. Eng. J.*, 2022, **448**, 137706.
- 10 K. Li, D. Feng and Y. Tong, *ChemSusChem*, 2022, **15**, e202200590.
- 11 X. Guo, M. Li, L. Qiu, F. Tian, L. He, S. Geng, Y. Liu, Y. Song, W. Yang and Y. Yu, *Chem. Eng. J.*, 2023, **453**, 139796.
- 12 L. Tan, J. Yu, C. Wang, H. Wang, X. Liu, H. Gao, L. Xin, D. Liu, W. Hou and T. Zhan, *Adv. Funct. Mater.*, 2022, **32**, 2200951.
- 13 S. M. N. Jeghan, D. Kim, Y. Lee, M. Kim and G. Lee, *Appl. Catal., B*, 2022, **308**, 121221.
- 14 H. Qi, P. Zhang, H. Wang, Y. Cui, X. Liu, X. She, Y. Wen and T. Zhan, *J. Colloid Interface Sci.*, 2021, **599**, 370–380.
- 15 A. Fauzi, S. Geng, F. Tian, Y. Liu, H. Li, Y. Yu, J. Li and W. Yang, *Int. J. Hydrogen Energy*, 2023, **48**, 1370–1379.
- 16 D. Wang, Y. Chen, L. Fan, T. Xiao, T. Meng, Z. Xing and X. Yang, *Appl. Catal., B*, 2022, **305**, 121081.
- 17 Y. Wu, Y. Li, M. Yuan, H. Hao, X. San, Z. Lv, L. Xu and B. Wei, *Chem. Eng. J.*, 2022, **427**, 131944.
- 18 H. Jing, P. Zhu, X. Zheng, Z. Zhang, D. Wang and Y. Li, *Adv. Powder Technol.*, 2022, **1**, 100013.
- 19 Z. Li, X. Wu, X. Jiang, B. Shen, Z. Teng, D. Sun, G. Fu and Y. Tang, *Adv. Powder Technol.*, 2022, **1**, 100020.
- 20 K. Sun, Y. Zhao, J. Yin, J. Jin, H. Liu and P. Xi, *Acta Phys.-Chim. Sin.*, 2022, **38**, 2107005.
- 21 A. Li, L. Zhang, F. Wang, L. Zhang, L. Li, H. Chen and Z. Wei, *Appl. Catal., B*, 2022, **310**, 121353.
- 22 Y. Dong, Z. Deng, Z. Xu, G. Liu and X. Wang, *Small Methods*, 2023, 2300071.
- 23 X. Zheng, X. Han, Y. Cao, Y. Zhang, D. Nordlund, J. Wang, S. Chou, H. Liu, L. Li and C. Zhong, *Adv. Mater.*, 2020, **32**, 2000607.
- 24 M. Yu, J. Zheng and M. Guo, *J. Energy Chem.*, 2022, **70**, 472–479.
- 25 Y. Liao, R. He, W. Pan, Y. Li, Y. Wang, J. Li and Y. Li, *Chem. Eng. J.*, 2023, **464**, 142669.

- 26 N. S. Gultom, H. Abdullah, C.-N. Hsu and D.-H. Kuo, *Chem. Eng. J.*, 2021, **419**, 129608.
- 27 M. Singh, T. T. Nguyen, J. Balamurugan, N. H. Kim and J. H. Lee, *Chem. Eng. J.*, 2022, **430**, 132888.
- 28 J. Song, Y. Chen, H. Huang, J. Wang, S. C. Huang, Y. F. Liao, A. E. Fetohi, F. Hu, H. y. Chen and L. Li, *Adv. Sci.*, 2022, **9**, 2104522.
- 29 Y. Huang, L.-W. Jiang, X.-L. Liu, T. Tan, H. Liu and J.-J. Wang, *Appl. Catal., B*, 2021, **299**, 120678.
- 30 J. Wang, D. T. Tran, K. Chang, S. Prabhakaran, D. H. Kim, N. H. Kim and J. H. Lee, *Energy Environ. Mater.*, 2023, **6**, e12526.
- 31 J. Balamurugan, T. T. Nguyen, D. H. Kim, N. H. Kim and J. H. Lee, *Appl. Catal., B*, 2021, **286**, 119909.
- 32 Q. Wang, R. He, F. Yang, X. Tian, H. Sui and L. Feng, *Chem. Eng. J.*, 2023, **456**, 141056.
- 33 S.-Q. Chang, C.-C. Cheng, P.-Y. Cheng, C.-L. Huang and S.-Y. Lu, *Chem. Eng. J.*, 2022, **446**, 137452.
- 34 A. Sun, Y. Qiu, X. Zheng, L. Cui and J. Liu, *J. Colloid Interface Sci.*, 2023, **632**, 108–116.
- 35 L. Tan, J. Yu, H. Wang, H. Gao, X. Liu, L. Wang, X. She and T. Zhan, *Appl. Catal., B*, 2022, **303**, 120915.
- 36 B. Zhang, J. Shan, W. Wang, P. Tsiakaras and Y. Li, *Small*, 2022, **18**, 2106012.
- 37 T. Yu, Q. Xu, L. Luo, C. Liu and S. Yin, *Chem. Eng. J.*, 2022, **430**, 133117.
- 38 Z. Li, M. Hu, P. Wang, J. Liu, J. Yao and C. Li, *Coord. Chem. Rev.*, 2021, **439**, 213953.
- 39 H. Zhang, A. W. Maijenburg, X. Li, S. L. Schweizer and R. B. Wehrspohn, *Adv. Funct. Mater.*, 2020, **30**, 2003261.
- 40 Q. Wen, K. Yang, D. Huang, G. Cheng, X. Ai, Y. Liu, J. Fang, H. Li, L. Yu and T. Zhai, *Adv. Energy Mater.*, 2021, **11**, 2102353.
- 41 C. Liu, Y. Han, L. Yao, L. Liang, J. He, Q. Hao, J. Zhang, Y. Li and H. Liu, *Small*, 2021, **17**, 2007334.
- 42 J. Liu, S. Xiao, X. Li, Z. Li, X. Li, W. Zhang, Y. Xiang, X. Niu and J. S. Chen, *Chem. Eng. J.*, 2021, **417**, 129279.
- 43 J. Hu, Y. Q. Liang, S. L. Wu, Z. Y. Li, C. S. Shi, S. Y. Luo, H. J. Sun, S. L. Zhu and Z. D. Cui, *Mater. Today Nano*, 2022, **17**, 100150.
- 44 J. Li, D. Chu, H. Dong, D. R. Baker and R. Jiang, *J. Am. Chem. Soc.*, 2019, **142**, 50–54.
- 45 J.-Y. Xue, F.-L. Li, B. Chen, H. Geng, W. Zhang, W.-Y. Xu, H. Gu, P. Braunstein and J.-P. Lang, *Appl. Catal., B*, 2022, **312**, 121434.
- 46 Y. Luo, Z. Zhang, M. Chhowalla and B. Liu, *Adv. Mater.*, 2022, **34**, 2108133.
- 47 S. Qiu, B. Zhang, X. Wang, J. Huang, G. Zhao, M. Ding and X. Xu, *J. Colloid Interface Sci.*, 2023, **641**, 277–288.